

# A Low Voltage CMOS Bandgap Reference without Using an Opamp

Edward K.F. Lee

Alfred Mann Foundation, 25134 Rye Canyon Loop, Suite 200, Santa Clarita, CA, USA  
edl@aemf.org

## ABSTRACT

A simple low voltage CMOS bandgap voltage reference that does not require an opamp is proposed. The major advantage of this design is in its low current consumption. Most of the total current consumption in the circuit is used for generating the output voltage. To improve the line regulation as well as the robustness of the design against process variations, a technique for modifying the feedback loop in the circuit was also proposed. Such modification does not require additional die area and power consumption. The proposed techniques were demonstrated with two low voltage bandgap reference designs using a conventional 0.18 $\mu\text{m}$  CMOS process. The reference that was designed with the proposed modified feedback loop achieved a temperature coefficient of  $< 10\text{ppm}/^\circ\text{C}$  and a line regulation of  $< 0.4\text{mV}/\text{V}$  with a current consumption of  $\sim 5\mu\text{A}$  from a 1V supply.

## 1. Introduction

Voltage reference is one of the most important analog building blocks and used in many digital and analog circuits such as DRAMs, flash memories, voltage regulators, analog-to-digital converters, etc. Most voltage references are usually designed based on a bandgap reference, which typically provides an output voltage of approximately 1.25V. As a result, the supply voltage for the reference needs to be greater than 1.25V. With the advance in CMOS processes, bandgap references with low supply voltages, such as  $< 1\text{V}$ , are required. To reduce the supply voltage, different voltage reference techniques have been developed [1] – [5]. Some of these techniques utilized devices that are compatible with CMOS processes such as Schottky diodes [2], dynamic threshold transistors (DTMOSTs) [3], gate-voltage difference of a MOSFET [4], etc. In this paper, bandgap voltage references based on parasitic bipolar devices are studied since they provide a more predictable voltage output even with process variations. As demonstrated in [5], a voltage reference circuit with a supply voltage of less than 1V was achieved using parasitic bipolar devices and a low voltage opamp. In this paper, an alternate low voltage bandgap reference topology that does not require an opamp is proposed. The main advantage of the proposed design is that, without an opamp, the main

current consumption of the circuit is that for generating the reference output voltage. As a result, the proposed bandgap reference can achieve low power consumption.

## 2. Existing CMOS Bandgap References

A typical CMOS bandgap reference without the use of an opamp [6] is shown in Fig. 1. With the feedback loop, which consists of  $M_1 - M_4$ , the source voltage of  $M_1$  is approximately equal to  $V_{EB2}$ . The voltage across  $R_1$ , referred to as  $\Delta V_{EB}$ , is ideally equal to the difference of the emitter voltages of  $Q_1$  and  $Q_2$ .  $\Delta V_{EB}$  can be written as  $V_t \ln(N)$ , where  $V_t = kT/q$  and  $N$  is the emitter area ratio of  $Q_2$  and  $Q_1$ . Assuming that the W/L ratios between  $M_1$  and  $M_2$  as well as among  $M_3 - M_5$  are the same,  $V_{ref}$  can be written as

$$V_{ref} = V_{EB3} + \frac{R_2}{R_1} \Delta V_{EB} \quad (1)$$

Since the negative temperature coefficient of  $V_{EB3}$  cancels out the positive temperature coefficient of  $\Delta V_{EB}$ ,  $V_{ref}$  has relatively small temperature dependence. Comparing with other conventional bandgap references that use an opamp, the advantage of this bandgap reference is that all the currents are used for generating  $V_{ref}$  directly. However, the minimum required supply voltage,  $\min[V_{DD}]$ , is approximately given by  $V_{EB} + V_T + 2V_{DSsat}$ . With  $V_T > 0.5\text{V}$  and  $V_{DSsat} > 0.1\text{V}$  for a MOSFET,  $\min[V_{DD}] > 1.4\text{V}$ .

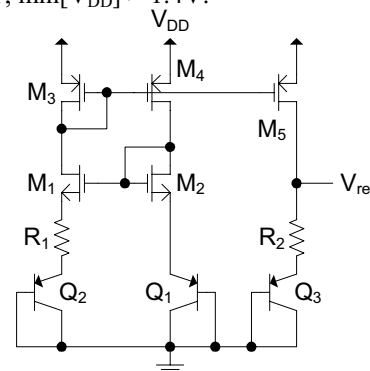


Fig. 1: Conventional bandgap without using an opamp

The bandgap reference described above has a relatively poor line regulation and this is mainly due to the differences in the MOSFET drain voltages. The line regulation can be shown to be inversely proportional to the output impedances of the MOSTETs, which can be improved using cascode technique.



## 4. Loop Gain Improvement

The relatively poor line regulation for the proposed reference is due to the mismatch in the currents through  $M_1$  and  $M_2$  that results in a voltage difference between  $V_x$  and  $V_y$ . Alternatively, this voltage difference can also be explained as a result of not having a sufficient loop gain to keep  $V_x$  and  $V_y$  the same under different parameter variations, including power supply variations as well as process variations. If the feedback loop consisted of  $M_1 - M_4$  in Fig. 3 is broken at the gate of  $M_1$ , the open loop gain from the source of  $M_1$  to node b can be shown to be approximately equal to  $g_{m1} \cdot (1/g_{m2} + z_y)$  where  $z_y$  is the impedance from the source of  $M_2$  looking into node y. To improve the loop gain, a modification on the feedback loop is proposed as shown in Fig. 5. The MOSFETs –  $M_1$  and  $M_3$  are split into  $M_{1a}$  and  $M_{1b}$  as well as  $M_{3a}$  and  $M_{3b}$  with a ratio of 1:k. In this case, the open loop gain is increased to  $\sim g_{m1a} \cdot [(g_{m2} \cdot r_{ds2} \cdot z_y) / r_4]$  where  $r_4$  is the output impedance of the self-cascode PMOS,  $M_4$ , and has a value of  $\sim g_m \cdot r_{ds}^2$ , which is usually greater than  $z_y$ . Notice that the small signal voltage change on node d does not affect the loop gain significantly since this voltage change on the gate of  $M_2$  is degenerated by  $z_y$ . Nevertheless, the increased overall loop gain will keep the voltage on node b close to the voltage on node d. Hence, the current flows through  $M_{1b}$  and  $M_2$  will match closely according to their W/L ratios. However, the ratio of the currents flowing through  $M_{1a}$  and  $M_{1b}$  will have a small error comparing to their W/L ratio values due to the difference in voltages between nodes a and d. Nevertheless, the overall current flowing through nodes x and y will have a relatively small overall matching error if k is large. Hence, the voltage difference between nodes x and y will be relatively small under different parameter variations. This modification does not cost any additional area and current consumption and reduce the variation on the output voltage significantly for different supply voltages and process variations as discussed in the next section. Nevertheless, depending on the current level of each branch, sometimes a small capacitor may be required to add between nodes a (or g) and b to ensure the stability of the feedback loop.

## 5. Simulation Results

The proposed bandgap references were designed based on a conventional 0.18 $\mu$ m CMOS process that provides parasitic PNP transistors, 1.8V MOSFETs as well as 3.3V MOSFETs for I/O circuits. The nominal  $V_T$  is  $\sim 0.5V$  for the 1.8V MOSFETs and  $\sim 0.7V$  for the 3.3V MOSFETs. The currents  $I_{D5-8}$  were selected to be  $\sim 1.1\mu A$ . The ratio between  $I_{D5-8}$  and  $I_{D3-4}$ ,  $\alpha$ , was set to

0.5. The emitter area ratio, N, was set to 8. For the voltage reference with the modified feedback loop shown in Fig. 5, the k factor was selected to be 3 and a compensation capacitor of 0.5pF was used. In both cases,  $V_{ref}$  was taken as the output voltage. The nominal output voltages were  $\sim 0.550V$  and  $\sim 0.563V$  for the bandgaps shown in Fig. 3 and Fig. 5, respectively. For the typical process corner, Fig. 6 shows the output voltages,  $V_{ref}$ , of the two proposed references at room temperature when the supply voltages were changed from 0 to 2V. Both references started to operate correctly for  $V_{DD} > \sim 0.85V$  and consumed  $\sim 5\mu A$  at 1V. The reference shown in Fig. 3 had a higher dependence on  $V_{DD}$ . The line regulations were 29.9mV/V and 0.37mV/V for the two bandgaps shown in Fig. 3 and Fig. 5, respectively. The supply rejections at 10Hz were 29dB and 64.7dB for the two bandgaps shown in Fig. 3 and Fig. 5, respectively. Due to the compensation capacitor used in the bandgap shown in Fig. 5 and the relatively low bias currents in both references, the supply rejection decreased at high frequencies. When the k factor changed from 3 to 1 and 7, the corresponding line regulations for the bandgap shown in Fig. 5 were 0.97mV/V and 0.19mV/V, respectively. These results demonstrated that the proposed reference with the modified feedback loop had compatible performances with the low voltage bandgap reference that used an opamp, which had a line regulation of  $\sim 7mV/V$  found in [5].

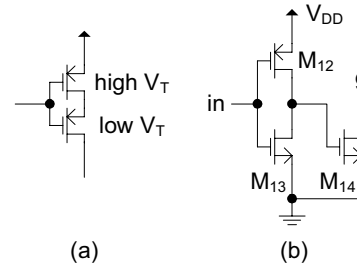


Fig. 4: (a) self-cascode PMOS and (b) startup circuit

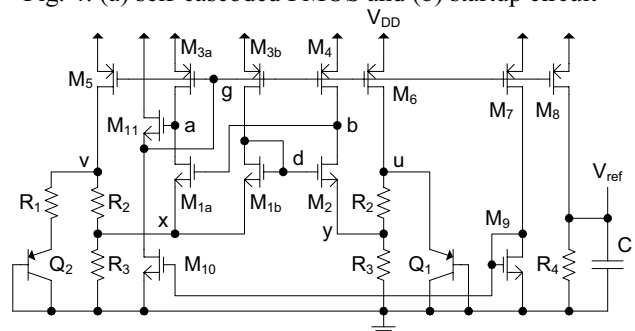


Fig. 5: Proposed bandgap with modified feedback loop

The two references were also simulated for different process corners with a supply voltage of 1V over a temperature range of  $-20^\circ C$  and  $100^\circ C$ . To better illustrate the effects of the feedback loop alone, only

the typical model for the bipolar transistors was used. The results are shown in Fig. 7a and 7b. For the typical process corner, the temperature coefficients were found to be  $< 9.0\text{ppm}/^\circ\text{C}$  for both designs. However,  $V_{\text{ref}}$  varied significantly over different process corners and temperatures for the reference shown in Fig. 3. The overall % changes on  $V_{\text{ref}}$  were between  $-1.28\%$  and  $+1.51\%$ . For the reference shown in Fig. 5, the overall % changes were between  $-0.14\%$  and  $+0.22\%$ . Based on the simulation results, it was demonstrated that the proposed bandgap reference with the modified feedback loop could operate at supply voltages less than 1V and was very robust against supply voltage and process variations. Table 1 summarizes the performances of the two proposed bandgap references.

## 6. Summary and Conclusion

In this paper, a low voltage bandgap voltage reference topology without the use of an opamp was proposed. The design required a low supply voltage that could be lower than 1V, and this was achieved by shifting down the operating voltage of the feedback loop using resistors. The reference voltage could be taken from two different nodes in the circuit. The required conditions for generating low temperature dependent output voltages taken from both nodes were described briefly. To improve the robustness against power supply and process variations, a modification of the feedback loop within the circuit was introduced. No increases in area and power are required with this modification. The two sub-1V bandgap references were designed based on a conventional  $0.18\mu\text{m}$  CMOS process to demonstrate the proposed techniques. Over 30dB improvement in the line regulation and approximately seven times improvement against the temperature and process variations were observed when the feedback loop was modified. The proposed topologies are relatively simple and easy to design. It can be used in many low voltage analog and digital ICs.

## REFERENCES

- [1] A. Boni, "Op-Amps and Startup Circuits for CMOS Bandgap References with Near 1-V Supply," IEEE J. of Solid-State Circ., vol. 37, pp. 1339-1343, Oct. 2002.
- [2] H. Banba et al., "A CMOS Bandgap Reference Circuit with Sub-1-V Operation," IEEE J. of Solid-State Circ., vol. 34, pp. 670-674, May, 1999.
- [3] A. Annema, "Low-Power Bandgap References Featuring DTMOSTs," IEEE J. of Solid-State Circ., vol. 34, pp. 949-955, Jul. 1999.
- [4] H. Hung et al., "A 1V  $16.9\text{ppm}/^\circ\text{C}$  250nA Switched-Capacitor CMOS Voltage Reference," ISSCC 2008 Dig. of Tech. Papers, pp. 438-439.

- [5] K. Leung and P. Mok, "A Sub-1-V  $15\text{-ppm}/^\circ\text{C}$  CMOS Bandgap Voltage Reference without Requiring Low Threshold Voltage Device," IEEE J. of Solid-State Circ., vol. 37, pp. 526-530, Apr. 2002.
- [6] B. Razavi, "Design of Analog CMOS Integrated Circuits." McGraw Hill. 2001.

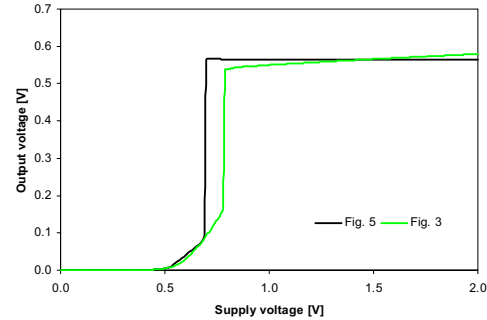
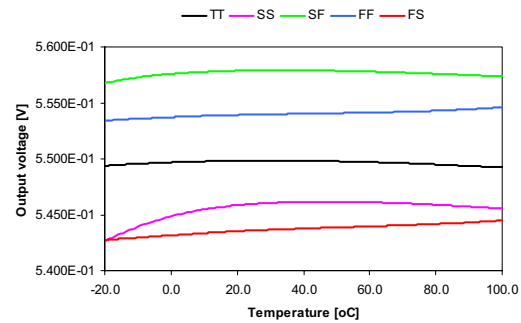
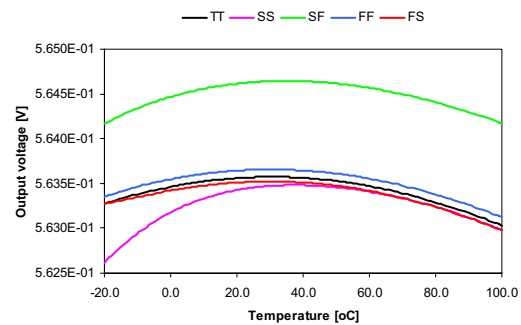


Fig. 6: Output voltages vs.  $V_{\text{DD}}$  for Fig. 3 and Fig. 5



(a)



(b)

Fig. 7: Output voltages vs. temperature with different process corners for (a) Fig. 3 and (b) Fig. 5

Table 1: Performance summary

Parameters	Fig. 3	Fig. 5
Current consumption	4.95 $\mu\text{A}$ @ 1V	5.07 $\mu\text{A}$ @ 1V
$V_{\text{DD}}$ range	0.85V – 1.8V	0.85V – 1.8V
Nominal output voltage	549.65mV	563.42mV
Line regulation	29.9mV/V	0.37mV/V
Power supply rejection	29.0dB @ 10Hz 25.1dB @ 10kHz	64.7dB @ 10Hz 8.7dB @ 10kHz
Temperature coefficient	9.0ppm/ $^\circ\text{C}$	8.0ppm/ $^\circ\text{C}$
Changes on temperature and process variations	$-1.28\% / +1.51\%$ $-7.0\text{mV} / +8.3\text{mV}$	$-0.14\% / +0.22\%$ $-0.8\text{mV} / +1.2\text{mV}$